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(54) Title: SPECTRAL PURITY FILTER, LITHOGRAPHIC APPARATUS, AND METHOD FOR MANUFACTURING A SPECTRAL PURITY FILTER

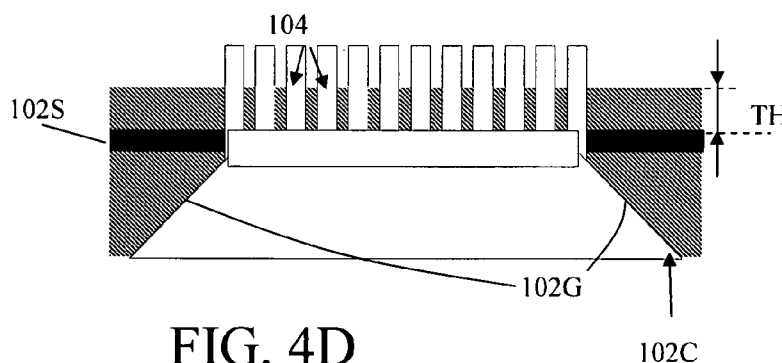


FIG. 4D

(57) Abstract: A transmissive spectral purity filter (100) is configured to transmit extreme ultraviolet radiation. The spectral purity filter (102F) includes a filter part (100) having a plurality of apertures (104) configured to transmit extreme ultraviolet radiation and to suppress transmission of a second type of radiation. Each aperture (104) has been manufactured by an anisotropic etching process.